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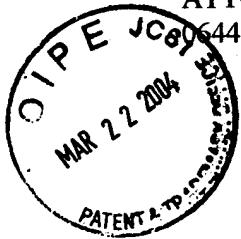
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**DECLARATION AND POWER OF ATTORNEY**

As a below named inventor, I hereby declare that:

My residence, post office address and citizenship are as stated below next to my name, that I believe I am the original, first and joint inventor of the subject matter which is claimed and for which a patent is sought on the invention, design or discovery entitled *Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process*, the specification of which is attached hereto as a Nonprovisional Application; that I have reviewed and understand the contents of the above-identified specification, including the claims, as amended by any amendment referred to above; that I do not know and do not believe that said invention, design or discovery was ever known or used in the United States of America before my invention or discovery thereof, or patented or described in any printed publication in any country before my invention or discovery thereof, or more than one year prior to this application, or in public use or on sale in the United States of America more than one year prior to this application; that said invention, design or discovery has not been patented or made the subject of an inventor's certificate issued prior to the date of this application in any country foreign to the United States of America on an application filed by me or my legal representatives or assigns; and that I acknowledge the duty to disclose to the U.S. Patent and Trademark Office all information known to me to be material to patentability as defined in 37 C.F.R. § 1.56.

I hereby claim foreign priority benefits under 35 U.S.C. § 119 of any foreign application(s) for patent or inventor's certificate listed below and have also identified below any foreign application(s) for patent or inventor's certificate having a filing date before that of the application on which priority is claimed:

<u>Number</u>	<u>Country</u>	<u>Date Filed</u>	<u>Priority Claimed</u> (Yes) (No)
None			

I hereby claim the benefit under 35 U.S.C. § 120 of any United States application(s) listed below and, insofar as the subject matter of each of the claims of this application is not

disclosed in the prior United States application(s) in the manner provided by the first paragraph of 35 U.S.C. § 112, I acknowledge the duty to disclose to the U.S. Patent and Trademark Office all information known to me to be material to patentability as defined in 37 C.F.R. § 1.56 which became available between the filing date of the prior application(s) and the national or PCT international filing date of this application:

<u>Application</u>	<u>Date Filed</u>	<u>Status</u>
<u>Serial Number</u>		
None		

I hereby claim the benefit under Title 35, United States Code, § 119(e) of United States provisional application number **60/422,010** filed **October 29, 2002**.

I hereby appoint:

Practitioners at Customer Number **31625**:

all of the firm of Baker Botts L.L.P., my attorneys with full power of substitution and revocation, to prosecute this application and to transact all business in the United States Patent and Trademark Office connected therewith, and to file and prosecute any international patent applications filed thereon before any international authorities.

Send Correspondence To:

Paula D. Heyman
The above-mentioned Customer Number

Direct Telephone Calls To:

at (512) 322-2581
Atty. Docket No. 064441.0266

I hereby declare that all statements made herein of my own knowledge are true and that all statements made on information and belief are believed to be true; and further that these statements were made with the knowledge that willful false statements and the like so made are punishable by fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that such willful false statements may jeopardize the validity of the application or any patent issuing thereon.

Title: *Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process*

Full name of joint inventor:

Xun Zhang

Inventor's signature



Date

01/09/04

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PATENT

4

Title: Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process

Full name of joint inventor:

Joseph Stephen Gordon

Inventor's signature



Joseph S. Gordon

1/10/03

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Title: Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process

Full name of joint inventor:

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6

Title: Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process

Full name of joint inventor:

Xiaoming Chen

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3/11/04

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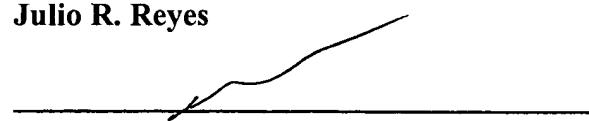
2109 Real Catorce
Austin, Texas 78746

Title: *Photomask Assembly and Method for Protecting the Same from Contaminants Generated During a Lithography Process*

Full name of joint inventor:

Julio R. Reyes

Inventor's signature



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10-29-2003

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